FORM PTO-1449 (REV. 7-80)

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

ATTY DOCKET NO. 800.1019

APPLICATION NO 10/529,028

APPLICANT

Sarina STRIEM et al.

FILING DATE

GROUP

(Use several sheets if necessary)

LIST OF PRIOR ART CITED BY APPLICANT

March 24, 2005

1625

## **U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE IF APPROPRIATE
/VO/	A01	2001/0007865	07/12/2001	KOZAK	514	143	
	A02						
	A03						
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	A08						
	A09						
	A10						

## **FOREIGN PATENT DOCUMENTS**

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION	
							YES	NO
/VO/	A11	WO 95/34302	12/21/1995	PCT	A61K	31/19		
/VO/	A12	WO 97/09976	03/20/1997	PCT	A61K	31/195		
/VO/	A13	WO 02/47674	06/20/2002	PCT	A61K	31/00		
	A14							
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Ţ.	OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)
A18	Abel-Hamid, K. M. et al. "Mechanisms and effects of intracellular calcium buffering on neuronal survival in organotypic hippocampal cultures exposed to anoxia/aglycemia or to excitotoxins" Journal of Neuroscience, New York, NY, US, Vol. 17, no. 10, 15 May 1997, pp. 3538-3553, XP002978437
A19	Krakovsky, M. et al. "DP-b99: A novel membrane-targeted compound active against global and focal cerebral ischemia" Physiological Imaging of the Brain with PET (2001), 347-352. Academic Press: San Diego, CA.
A20	Krakovsky, M. et al. Abstract: "DP-b99: A novel membrane-targeted compound active against global and focal cerebral ischemia", (2001)Chemical Abstracts Service, Columbus, OH, US
A21	Copy of Supplementary European Search Report issued in corresponding European Patent Application No EP 03 71 0190
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/Taylor Oh/ (03/16/2009)

**DATE CONSIDERED** 

03/16/2009

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.